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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/665,206	09/22/2003	Tetsuya Kurosawa	04173.0438	5743
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Finnegan, Henderson, Farabow,			OSELE, MARK A	
Garrett & Dunn	er, L.L.P.			
1300 I Street, N.W.			ART UNIT	. PAPER NUMBER
Washington, DC 20005-3315			1734	
			DATE MAILED: 08/24/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)			
Office Action Summary		10/665,206	KUROSAWA, TETSUYA			
		Examiner	Art Unit			
		Mark A Osele	1734			
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
A SHORTENED S THE MAILING DA - Extensions of time ma after SIX (6) MONTHS - If the period for reply s - If NO period for reply i - Failure to reply within the serious days are serious and serious an	STATUTORY PERIOD FOR REPLY ATE OF THIS COMMUNICATION.  by be available under the provisions of 37 CFR 1.13 from the mailing date of this communication. pecified above is less than thirty (30) days, a reply is specified above, the maximum statutory period whe set or extended period for reply will, by statute, the Office later than three months after the mailing justment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be timed within the statutory minimum of thirty (30) days will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).			
Status						
1) Responsive	to communication(s) filed on	_·				
2a) This action	is <b>FINAL</b> . 2b)⊠ This	action is non-final.				
	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claim	s					
4a) Of the all 5) ☐ Claim(s) 6) ☑ Claim(s) 1-7) ☐ Claim(s)	14 is/are pending in the application. bove claim(s) is/are withdrav is/are allowed. 44 is/are rejected is/are objected to are subject to restriction and/or	vn from consideration.				
Application Papers						
9)☐ The specific	ation is objected to by the Examine	r.				
10)⊠ The drawing(s) filed on <u>22 September 2003</u> is/are: a)⊠ accepted or b)☐ objected to by the Examiner.  Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).  11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.						
Priority under 35 U.S	S.C. § 119					
<ul> <li>12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a) All b) Some * c) None of:</li> <li>1. Certified copies of the priority documents have been received.</li> <li>2. Certified copies of the priority documents have been received in Application No</li> <li>3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>						
Attachment(s)						
1) Notice of References Cited (PTO-892)  4) Interview Summary (PTO-413)						
2) Notice of Draftsperso	on's Patent Drawing Review (PTO-948) re Statement(s) (PTO-1449 or PTO/SB/08)	Paper No(s)/Mail Da				

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#### DETAILED ACTION

# Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 2. Claims 1, 4, 6-8, are rejected under 35 U.S.C. 102(b) as being anticipated by Nam et al. Nam et al. shows a method and apparatus for manufacturing a semiconductor device comprising: sectioning semiconductor elements, 72, from a semiconductor wafer; picking up the sectioned semiconductor element from a holding member, 56; sticking an element adhesive film, 68, which is sectioned according to the shape of the semiconductor element, to the back surface of the element; and adhering the semiconductor element to a semiconductor device forming base material, 66, by the adhesive film (paragraphs 0027-0030).

Regarding claims 4 and 7, the adhesive film is supplied from a supply roll and cut according to the shape of the semiconductor element by mechanical cutting using a knife, 48 (paragraph 0028).

Regarding claim 8, the film cutting section has an adsorption member, 52, for holding the adhesive film and a cutting mechanism, 48, for cutting the element adhesive film held by the adsorption member.

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# Claim Rejections - 35 USC § 103

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3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

- 4. Claims 2, 3, and 12 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nam et al. in view of Sasaki et al. Sasaki et al. teaches that it is conventional to adhere a first holding member to the front of a semiconductor wafer, backgrind the rear of the wafer, apply a second holding member to the rear of the wafer, dice the wafer from the front of the wafer, and use push up pins to separate the semiconductor element from the second holding member (column 1, line 26 to column 2, line 7). It would have been obvious to one of ordinary skill in the art at the time the invention was made to add the conventional steps of Sasaki et al. into the method of Nam et al. in order to create the diced wafer of Nam et al. because these steps are shown to be the conventional approach to creating individual elements on a holding member.
- 5. Claims 5 and 14 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nam et al. in view of Bura et al. As shown in paragraph 2 above, Nam et al. shows all of the instantly claimed limitations except for applying the tape to the back of the semiconductor element using the porous adsorption member.

Bura et al. teaches that applying adhesive to the semiconductor element rather than the base material is advantageous because the semiconductor element provides

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an accurate guage for how much adhesive to apply (column 2, lines 13-17). It would have been obvious to one of ordinary skill in the art at the time the invention was made to apply the adhesive film of Nam et al. onto the semiconductor element rather than the base material because Bura et al. teaches this system to yield greater accuracy of adhesive application.

In addition, Bura et al. teaches the use of a protective foil on the adhesive film adhered to the semiconductor element which is peeled off prior to bonding the semiconductor element to the base material (column 2, lines 46-53).

- 6. Claim 9 is rejected under 35 U.S.C. 103(a) as being unpatentable over Nam et al. in view of Rogowski. As shown in paragraph 2 above, Nam et al. shows all of the instantly claimed limitations except for the adsorption member to be made of a porous metal. Rogowski teaches that porous metal plates over vacuum sinks allow for positioning of light weight sheets without deforming the sample into the pore sinks (column 4, lines 51-59). It would have been obvious to one of ordinary skill in the art at the time the invention was made to use a porous metal adsorption member in the apparatus of Nam et al. because Rogowski teaches that these are advantageous in preventing deformation when positioning thin sheets and the adhesive film of Nam et al. is a thin sheet.
- 7. Claim 10 is rejected under 35 U.S.C. 103(a) as being unpatentable over Nam et al. in view of either Wojewnik et al. or Varaprasad et al. As shown in paragraph 2

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above, Nam et al. shows all of the instantly claimed limitations except for the cutting means to be a laser. Wojewnik et al. and Varaprasad et al. each teach that laser cutters and cutting blades are interchangeable when cutting a film to a desired shape for bonding to a substrate (Wojewnik et al., column 4, lines 43-48; Varaprasad et al., column 32, lines 27-39). It would have been obvious to one of ordinary skill in the art at the time the invention was made to replace the cutting blade of Nam et al. with a laser cutter because Wojewnik et al. and Varaprasad et al. each show them to be interchangeable for the purpose of cutting a bondable film to the shape of a substrate.

8. Claim 11 is rejected under 35 U.S.C. 103(a) as being unpatentable over Nam et al. in view of either Wojewnik et al. or Varaprasad et al. as applied to claim 10 above and further in view of Rogowski. As shown in paragraph 7 above, the references as combined show all of the instantly claimed limitations except for the adsorption member to be made of a porous metal. Rogowski teaches that porous metal plates over vacuum sinks allow for positioning of light weight sheets without deforming the sample into the pore sinks (column 4, lines 51-59). It would have been obvious to one of ordinary skill in the art at the time the invention was made to use a porous metal adsorption member in the apparatus of the references as combined because Rogowski teaches that these are advantageous in preventing deformation when positioning thin sheets and the adhesive film of the references as combined is a thin sheet.

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9. Claim 13 is rejected under 35 U.S.C. 103(a) as being unpatentable over Nam et al. in view of as Sasaki et al. applied to claim 12 above and further in view of Rogowski. As shown in paragraph 4 above, the references as combined show all of the instantly claimed limitations except for the adsorption collet to be made of a porous metal. Rogowski teaches that porous metal plates over vacuum sinks allow for positioning of light weight sheets without deforming the sample into the pore sinks (column 4, lines 51-59). It would have been obvious to one of ordinary skill in the art at the time the invention was made to use a porous metal adsorption member in the apparatus of the references as combined because Rogowski teaches that these are advantageous in preventing deformation when positioning thin sheets and the electronic component of the method of the references as combined, although not a thin film, might be damaged by bending to the shape of a non-flat adsorption member.

# Claim Objections

10. Claim 6 is objected to because of the following informalities: In line 11, "film is stack," is not idiomatic English. Claim 14 is objected to because of the following informalities: In line 5, "film stack to" is not idiomatic English Appropriate correction is required.

# Conclusion

11. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Moden and Abe et al. each show bonding semiconductor

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devices to a substrate using an adhesive film. Kranzler et al. shows a porous metal plate over a vacuum means for holding a thin film. Nishiyama shows that cutting blades and laser cutters are interchangeable in semiconductor manufacturing.

12. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Mark A Osele whose telephone number is 571-272-1235. The examiner can normally be reached on Mon-Fri 9:30-6:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Christopher Fiorilla can be reached on 571-272-1187. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

PRIMARY EXAMINER

August 23, 2004